Carbon-based Resistive Memory

Franz Kreupl, Rainer Bruchhaus⁺, Petra Majewski , Jan B. Philipp, Ralf Symanczyk, Thomas Happ^{*}, Christian Arndt^{*}, Mirko Vogt^{*}, Roy Zimmermann^{*}, Axel Buerke^{*}, Andrew P. Graham^{*}, Michael Kund



Qimonda AG, +Qimonda North America, *Qimonda Dresden GmbH & Co. OHG franz.kreupl@qimonda.com

Outline of Presentation

- Introduction and Motivation
- Basic Switching in Carbon
- Carbon Allotropes
- Carbon Nanotubes
- Graphene-like Conductive Carbon
- Insulating Carbon
- Conclusions

Introduction and Motivation

Resistive Memories like

- Phase Change (Ge_xSb_yTe_z,....)
- *Nano-Ionic, (*CBRAM-like, e.g. Ag₂S, Ag-GeSe, Cu₂S....)
- Transition-Metal-Oxide (NiO, TiO₂,....)
 are very promising memory technologies
- but are binary, ternary or even more complex materials:
 - what about scalability
 - how do they respond to volume/surface ratio
 - what about variability, if scaled

• Are there other, simpler materials available?

Introduction and Motivation

• The available current in a memory cell is given by the select device (FET, diode)

An upper limit may be estimated by: $j = e_*N_{d^*}v_{sat} = e_*10^{19}*10^7 = 16 \text{ MA/cm}^2$

 Typical currents in phase change memories are ~10 MA/cm²
 Are there options or materials which enable switching at low currents (some µA)?

Bit Line

Ga

resistive

memory

element

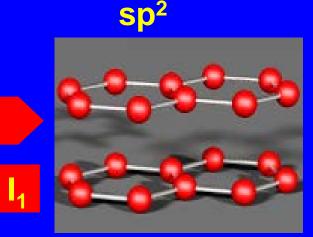
S

Introduction: Carbon Memory

sp³









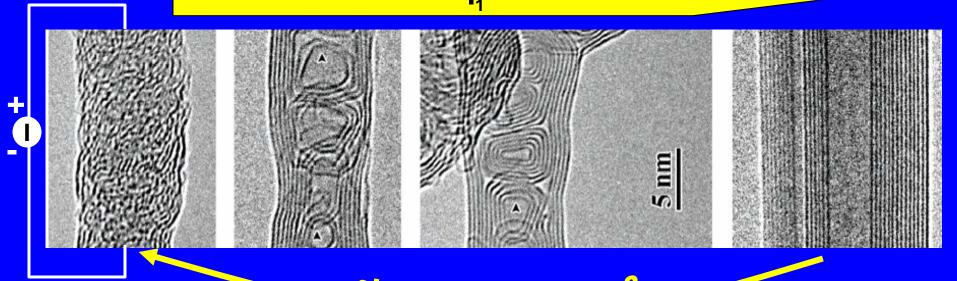
low conductance

high conductance

sp² to sp³ conversion of disordered graphitic carbon (phase change of carbon)

inherently scalable to atomic scale (no phases of different materials)

Basic Switching in Carbon

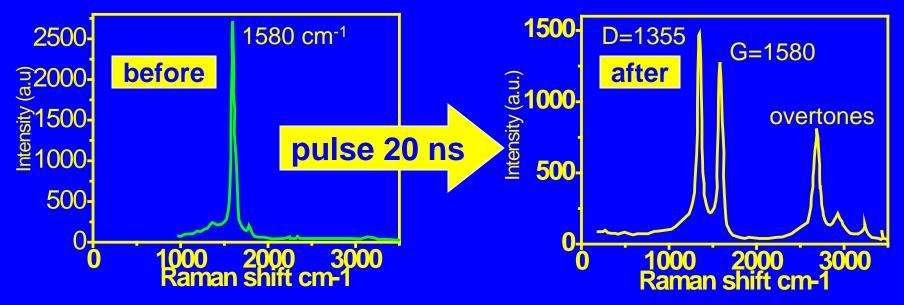


Short current pulse?

- Current changes structure and resistance
- Resistance changes by a factor of ~ 100
- High → Low well known from e-fuses
- New: switch to disorder by short pulse

TEM image by courtesy of J. Huang et al., Nano Letters 2006 Vol. 6, No. 8 pp. 1699-1705

Short Laser Pulses on Graphite



- Short laser pulse induces disorder (D-band)
- D-band overlaps with sp³-peak at 1332 cm⁻¹
- Diamond cubic phase observed by e-beam diffraction

Disordered, quenched state by short energy pulse

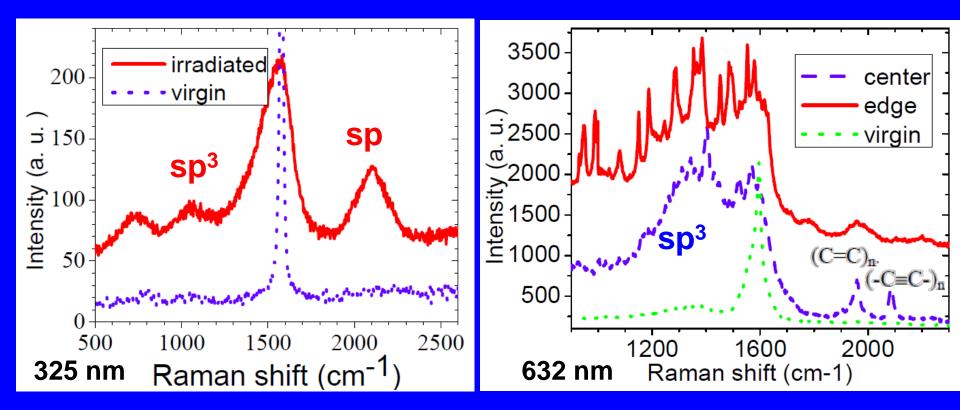
F. Kreupl et al.

Bonelli et al., Laser-irradiation-induced structural changes on graphite, Phys. Rev. B 59, 13513 (1999) 7

 $0 2\overline{2}$

 $1 1 \overline{1}$

3 ps Laser Pulse on Graphite



The shorter the laser pulse the more disorder
 Disordered, quenched state by short energy pulse

source: Anming Hu, PhD Thesis, U Waterloo, 2008 F. Kreupl et al.

Short Energy Pulses

 Fluence of the laser pulse at graphite ablation threshold =~ 285 mJ/cm²
 K. Sokolowski-Tinten et al., CLEO 2000

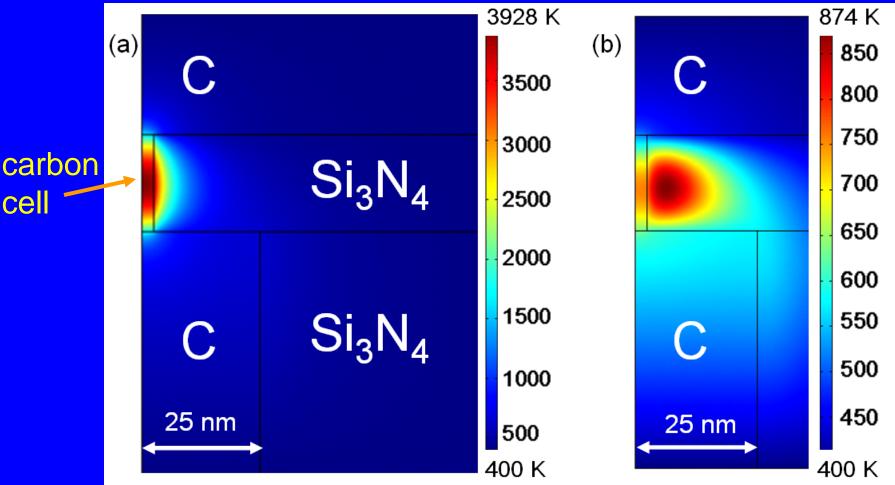
Energy density (energy/volume) = <u>95 KJ/cm³</u>

• Energy density for a wire subjected to a current:

 $E/V = j^2 \rho t = 1GA/cm^2 \cdot 1m\Omega cm \cdot 20 ns = 2 MJ/cm^3$

Disordered, quenched state by short current pulse

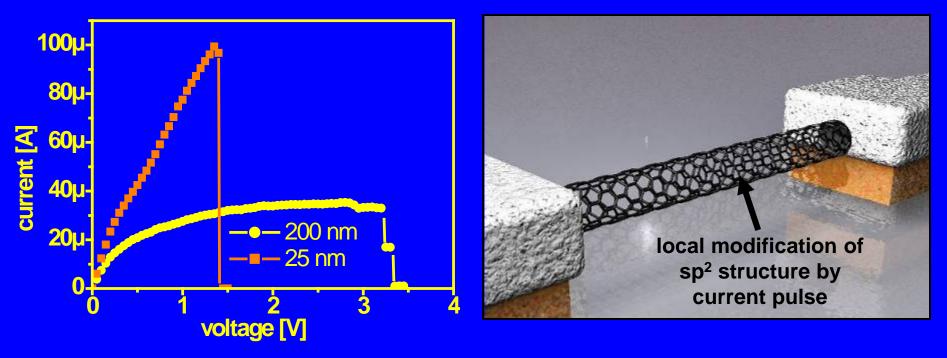
Short Current Pulse



temperature distribution in carbon filament after 1 ns current pulse with 1.7 GA/cm² : T_{peak} ~ 3900 K; rapid cool down (0.05 ns)

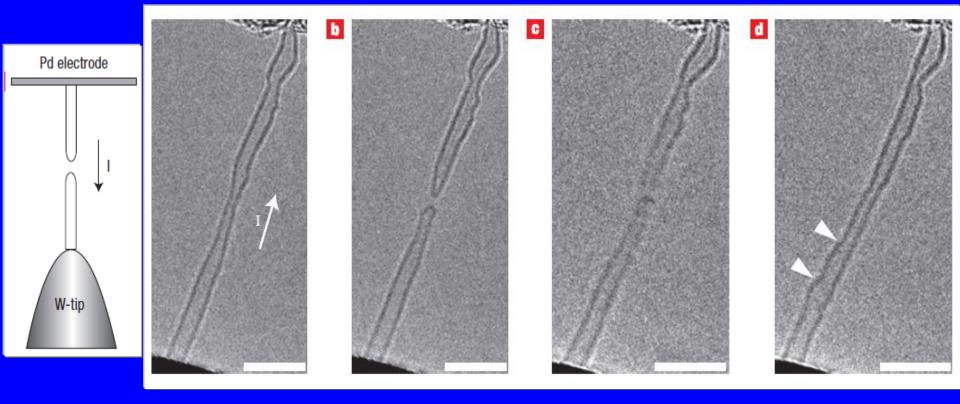
10

Carbon Nanotubes



- Nanotubes have a length dependent switching current
- 25 nm long tubes need ~ 100µA @ 1.5 V and have no phonon-limited transport
- tubes > 200 nm need ~ 30 μA @ 4V (phonon-limited)
- Select device needs to handle ~ 30 µA and 4-8 Volt

Carbon Nanotubes In vacuum ~ 12 µA current possible



on-state off-state switch on on-state 12 uA 6 uA, 1.6V

Jin et al., nature 18 nanotechnology | VOL 3 | JANUARY 2008 |

Allotropes of Carbon (investigated)

Carbon Nanotubes

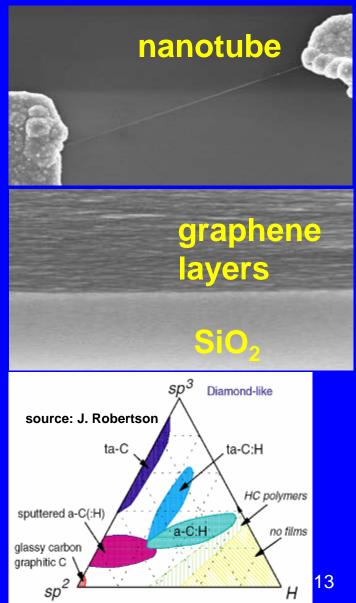
- sp²-type
- difficult to integrate
- high conductivity

Graphene or Conductive Carbon

- sp²-type
- easy to integrate
- high conductivity

Insulating carbon

- sp³-type, diamond-like
- easy to integrate
- high resistivity



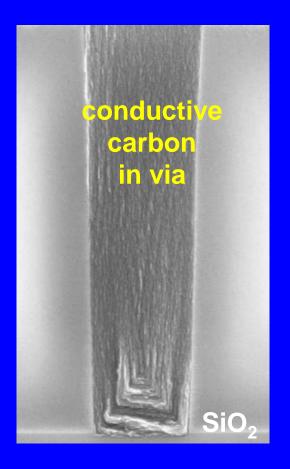
Conductive Carbon (CC)

Conductive Carbon is

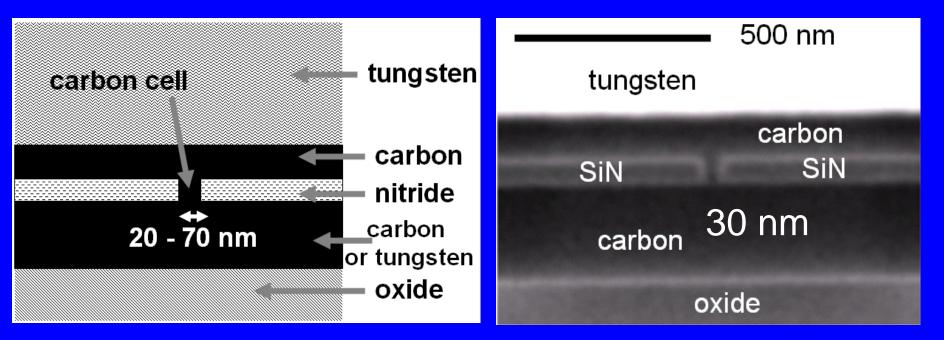
- graphene-like
- easily deposited (CVD)
- can be used as interconnect material (highly conductive)
- easy to pattern

R. Seidel. et al., Chemical Vapor Deposition Growth of Single-Walled Carbon Nanotubes at 600 °C and a Simple Growth Model *J. Phys. Chem. B*, (2004)

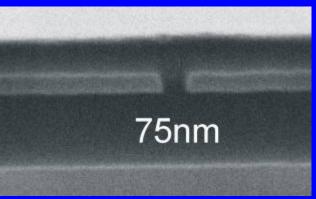
G. Aichmayr et al., **Carbon-high-k Trench Capacitor** for the 40nm DRAM Generation, **VLSI** Technology, (2007)



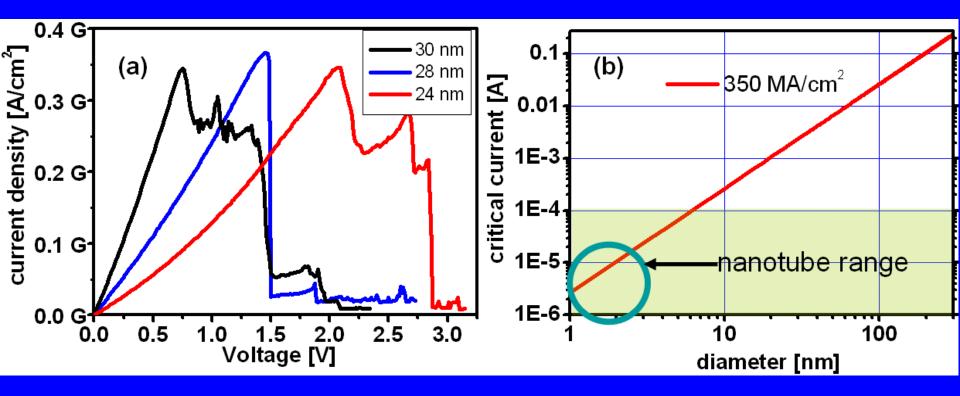
Conductive Carbon: Memory Cell



Carbon memory cells with varying diameter



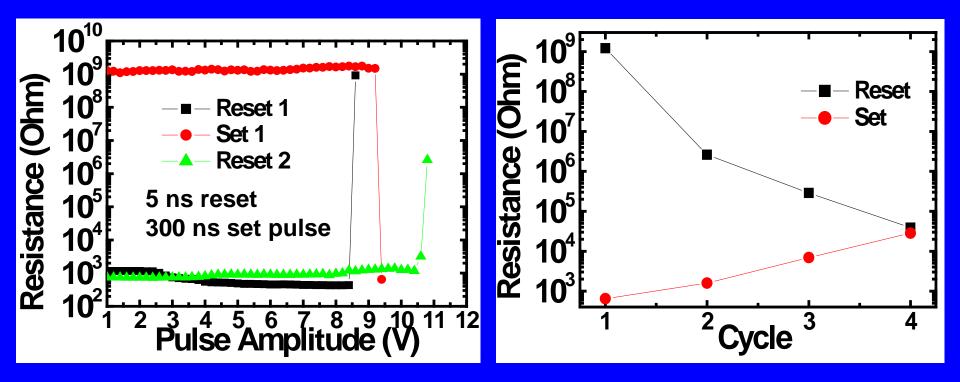
Conductive Carbon: Critical Current



Critical current density of 350 MA/cm² observed

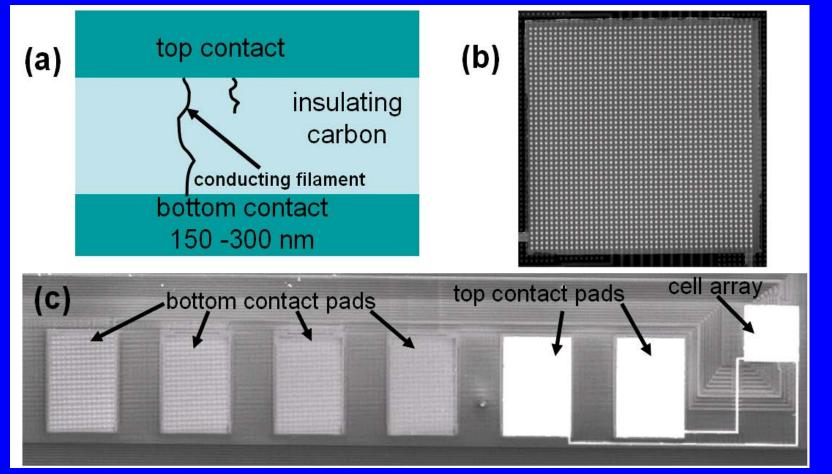
- Appropriate cell diameter ~ 6 nm for I < 100 μA
- Use spacer, cladding or self-assembled nano-pores

Conductive Carbon (CC): Switching



Shmoo-plot of 40 nm diameter CC memory cell
 smaller diameter, current compliance and optimized pulses required

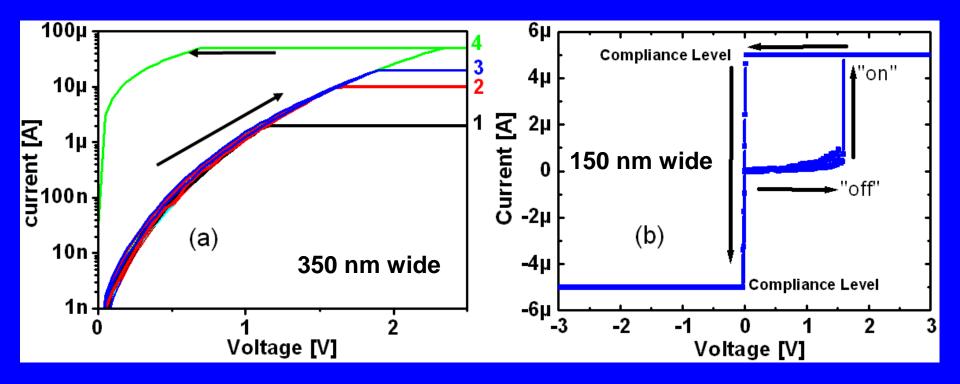
Insulating Carbon (IC): Memory Cell



Insulating diamond-like carbon film

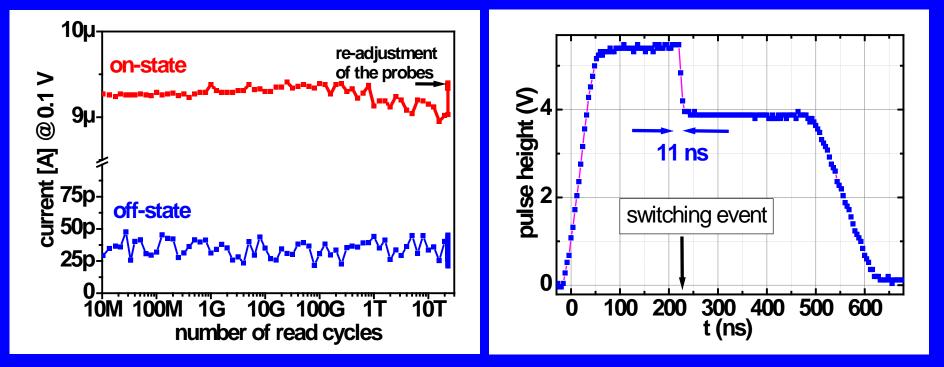
First switching occurs now from high to low state

Insulating Carbon (IC): Critical Field



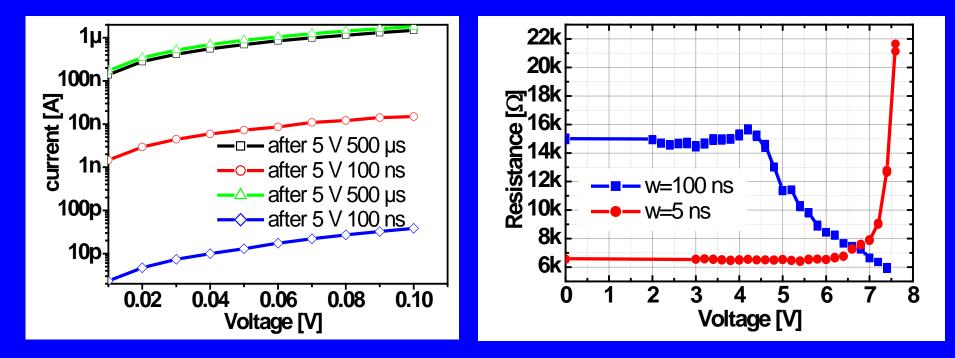
- Quasi-static switching curves determine critical field
- Switching power is about 50µW with leakage currents.
- Very low power levels: 5 μA @ 1.5 V (P= 7.5 μW)

Ins. Carbon: Read Endurance & Speed



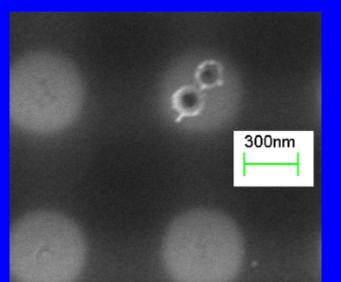
Read endurance at 75 degree C: 2.3*10¹³ read cycles at 0.1 V.
Switching speed is faster than 11 ns.

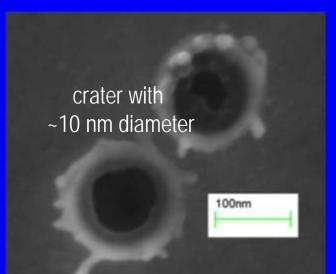
Insulating Carbon: Switching



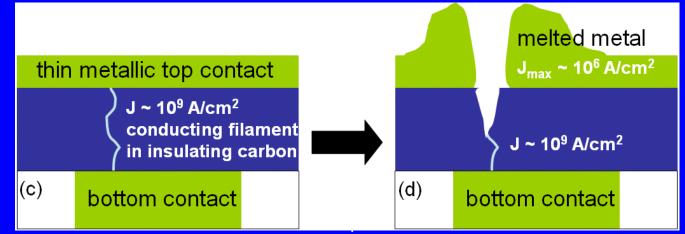
- I(V) curves show similar behavior after pulses
- Resistance level can be trimmed by individual voltage pulses (multi-level capability)

Insulating Carbon: Filament size





10 V pulse evaporates metal → filament ~ 10 nm @ 10 V → use carbon as current spreader



Conclusions

- New carbon memory proposed based on sp² to sp³ conversion
- Inherently fast: reset ~ ns, set ~ ns
- Nanotubes need ~30 µA @ 8V
- Graphene-like Conductive Carbon needs pores < 6 nm
- Insulating Carbon shows lowest switching power: 5 μA @ 1.5 V (P= 7.5 μW)
- Pulses and cell design needs to be optimized
- Should also work with Fullerens, Graphene and Diamonds

Acknowledgement Qimonda Fab Dresden Roland Thewes, Thank you! Werner Pamler, Walter Weber, Uli Klostermann, **Klaus-Dieter Ufert**, **Henning Riechert Stanford University Questions?**